

Project:

Self-Cleaning and continuous protection of porous building surfaces such as cement, stones, walls and grout

Product:

SurfaShield C

Key Benefits:

- Self Cleaning
- Self Sterilizing
- Superhydrophilic
- Decomposes Odours
- Air purifier
- Continuous Action
- Environmentally friendly cleaning technology

Applications:

- Self-Cleaning of Walls
- Protection from mould growth and organic stains
- Stone and Monument Protection
- Environmental Restoration
- Prevents pollutants adhesion
- Decomposes Pollutants
- Bacterial Growth Inhibition
- Exhaust Gas Break-Down

Packaging:

1L, 4L, 10L, 30L Containers, 1000L IBCs

www.NanoPhos.com



SurfaShield® C

Photocatalytic Self-Cleaning Nanotechnology for the Protection of Porous Surfaces

SurfaShield C decomposes organic stains and pollutants, prevents microbial growth, purifies the air, removes odours. It is an active nanotechnology formulation that can be easily applied on exterior porous surfaces, such as cement, render or plaster, mortar grout, walls, stones or even unpolished marble. By harnessing the surrounding light, treated surfaces become Self Cleaning and Self Sterilizing. SurfaShield coated surfaces efficiently decompose organic stains, bacteria, mould, gaseous pollutants, even odours. SurfaShield C modified surfaces are safer, without the need to use hazardous disinfectants or chemicals, and are preserved as new.



5 GAIA
THE BIG AWARDS
2010
FINALIST

SurfaShield® is a registered trademark of
NanoPhos SA
PO Box 519,
Science & Technology Park of Lavrio
Lavrio 19500, Greece
T: +302292069312 F: +302292069303
E: info@NanoPhos.com

NanoPhos
Pioneering
Nanotechnology 

SurfaShield C Description

SurfaShield C is a liquid formulation, developed and produced by NanoPhos SA, that provides effective self cleaning and self sterilizing properties on a wide range of porous building surfaces. By harnessing nanotechnology achievements, effectiveness, continuous action and minimal change to the original natural appearance of the application surface are assured. SurfaShield C acts by absorbing surrounding light and transforming it in chemical power. As a semi-conducting catalyst, SurfaShield C nanoparticles are activated by light to produce short-living oxidizing compounds: oxygen and hydroxyl radicals. Bacteria, Viruses, Mold, Gaseous Pollutants, Odours, Stains; they all decompose and break down to harmless inorganic compounds. Thus the application surfaces remain actively clean. The treated surfaces become super-hydrophilic and as a result pollutants are washed away. SurfaShield also acts as an air purifier as it decomposes harmful organic substances such as volatile organic compounds (VOC), car exhaust fumes and nitrogen oxides (NOx). As a result nanotechnology assures permanently cleaning and safer environment just by absorbing light.

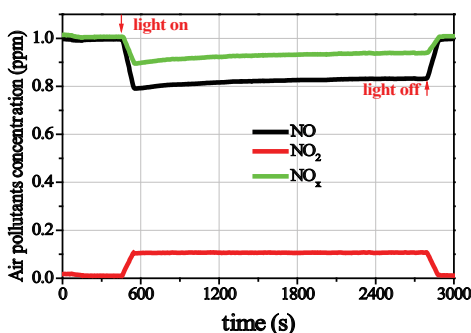


International Standards Testing

Antibacterial Action (ISO EN 27447, ETAT SA): Deactivation of bacterial microorganisms *Escherichia coli* (ATCC 51813): 98,92%, *Listeria monocytogenes* (ATCC 19115): 99,89% and *Staphylococcus aureus* (ATCC 6538) 99,68% within four hours of exposure under environmental light of intensity: $55,6 \mu\text{W}\cdot\text{cm}^{-2}$ (360-420nm).

Antifungal Action (ISO EN 27447, ETAT SA): Deactivation of fungi microorganisms *Aspergillus* and *Penicillium* spores: 87,27% within four hours of exposure under environmental light of intensity: $55,6 \mu\text{W}\cdot\text{cm}^{-2}$ (360-420nm).

Removal of nitric oxide (ISO 22197-1:2007): Photocatalytic activity was measured as the oxidation of NO under UV light (350 nm, 10 W/m²). NO gas is adsorbed on photocatalyst surface and is oxidized producing NO₂ gas and nitric ions (NO₃⁻).



Application Note

Surface Application: Shake or stir the container vigorously before use. The application surface should be dry and clean. Apply SurfaShield C with a brush, roller or spray gun. No dilution is required. If any excess remains on the application surface, remove by using a wet cloth. On very absorptive surfaces re-apply a second coating. The application of SurfaPore C or SurfaPore M 24h prior to SurfaShield C application is recommended, in order to reduce water or stain penetration. **Consumption:** Estimated consumption rate 8-10 m²/L, strongly dependent on the properties of the surface applied. **Expiration Date:** 18 months after the production date.

Physical Properties

White, Water based suspension with pH = 9.2±0.5. Contains less than 10%w/w isopropanol. Flash Point (closed cup method): 41°C Density: 0.98±0.05 g·cm⁻³ Viscosity: 2 mPa·s VOC content: 136 g/L SurfaShield C is not an oxidant.

Safety & Storage

Fammable liquid and vapour. Causes serious eye irritation. Keep away from heat, sparks, open flames and hot surfaces. No smoking. Keep container tightly closed. Wear protective gloves / eye and face protection. IF ON SKIN (or hair): Take off immediately all contaminated clothing. Rinse skin with water / shower. If eye irritation persists: Get medical advice / attention. Avoid breathing dust / mist / spray. Use only outdoors or in a well-ventilated area. In case of fire: use carbon dioxide, foam, chemical powder to extinguish.



What is Nanotechnology?

Nanotechnology refers to the scientific field, which deals with the research and creation of small matter particles, usually sized below 100 nm. One nanometer (nm) is one billionth of a meter (10⁻⁹ m) - it is so small that if earth were one meter in diameter, then one nanometer would have been the size of an apple! Nanosized materials reveal unique properties when compared to ordinary, bulk materials or even molecules.

NanoPhos at a Glance...

At NanoPhos, we take advantage of the unique properties of nanotechnology and invent clever materials that solve every day problems. By harnessing nanotechnology, we seek to create a more comfortable, safe and trouble-free living environment. We transfer innovations out of our lab and into the hands of consumers. Our vision is clear: "Tune the nanoworld to serve the macroworld" – in simple terms we make nanoparticles to solve common problems. NanoPhos was recognized in January 2008 by Bill Gates as one of the most innovative companies and also received the 1st prize for innovation at the prestigious 100% Detail Show in London. NanoPhos is a rapidly growing company that is actively expanding its distribution network. Currently, the company is present in the UK, Norway, Sweden, Denmark, Portugal, Spain, France, Italy, Greece, Cyprus, Egypt, Sudan, Saudi Arabia, Bahrain, UAE, Qatar, Oman, Iran, India, New Zealand, China, Japan, Mexico, Guatemala, Thailand, Malaysia and Singapore.

www.NanoPhos.com



NanoPhos SA has been approved by Lloyd's Register Quality Assurance to follow the EN ISO 9001:2000 Quality Management System and the environmental management system EN ISO 14001:2004 for the development, production and sales of chemical products for cleaning and protection of surfaces and nanotechnology products. Furthermore, it is certified for occupational health and safety management systems with OHSAS 18001:2007.

LIMITED WARRANTY INFORMATION – PLEASE READ CAREFULLY. The information contained herein is offered in good faith and is believed to be accurate. However, because conditions and methods of use of our products are beyond our control, this information should not be used in substitution for customer's tests to ensure that NanoPhos' products are safe, effective, and fully satisfactory for the intended end use. Suggestions of use shall not be taken as inducements to infringe any patent. NanoPhos specifically disclaims any other express or implied warranty of fitness for a particular purpose or merchantability. NanoPhos disclaims liability for any incidental or consequential damages. This product is neither tested nor represented as suitable for medical or pharmaceutical uses.